# GalnNAs Lasers

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# Outline

Applications, why the interest?

Previous option (InGaAsP)

Problems

GalnNAs Material Properties

Benefits

- Research Results
  - □ Issues and future work

# Applications

#### Network capacity is increasing exponentially

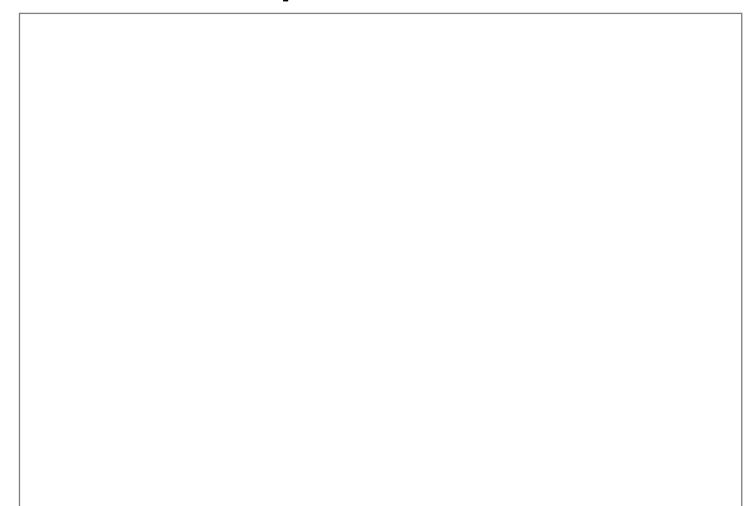
- Gilder's Law "Communication Capacity will triple every 12 months"
- Need long wavelength, high speed, low cost VCSEL





 Advantages of long wavelengths (>1300nm) relative to short wavelengths (850nm)

# **Material Properties**



# InGaAsP as an Option

- InGaAsP/InP is the current material system in use in VCSELs for 1.3/1.55 μm
- Major problems and disadvantages:
  - High cost
- Poor T performance:
  - □ Small band offset (leads to To~70K)
  - DBRs have low thermal conductivity
- Unsatisfactory VCSEL performance:
  - Poor DBR mirrors
  - Elaborate Structure/More cost
- GalnNAs offers several benefits

# Compared to GalnNAs

- Larger refractive index differences

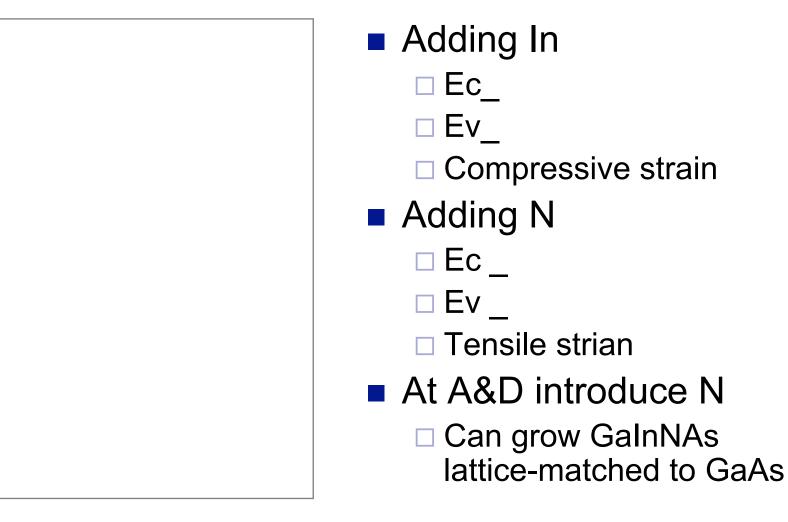
   Step difference ∆n(AlGaAs)> ∆n(InGaAsP)
   Easier to make high reflectivity DBRs

  Thermal conductivity

   Bottom DBR acts as better heat sink

  Cheaper GaAs substrates
- Larger conduction band offset
  - Better temperature performance

# **Material Properties**

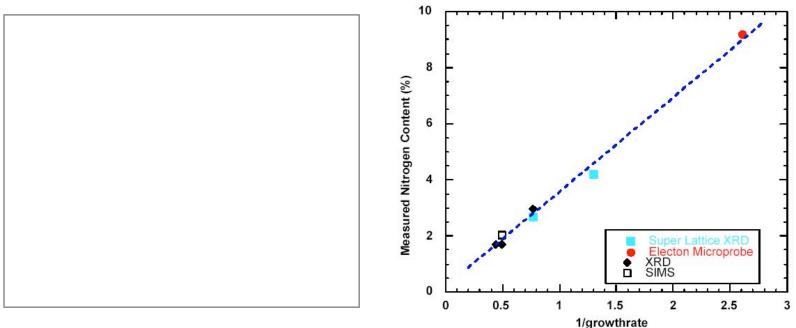


## **Material Properties**



- Much greater  $\Delta Ec$  for GalnNAs
  - -Suppresses electron overflow from QW
  - -dramatically improves temperature characteristics

## Growth



- Grown by MBE with RF nitrogen plasma
- N incorporated with unity sticking coefficient
  - □ Better yield and reproducibility

VCSEL
 structure
 Mesa etch
 AlOx aperture

- First generation VCSEL design
- 1200nm output
  - CW at room temperature
  - □ J<sub>th</sub>≈2kA/cm²
  - □ Slope efficiency≈0.05W/A





- Add Sb to well layer
  More In content
- Add N, Sb to barrier layer
  - □ Strain compensation
- Increase output wavelength
- Added complexity

#### Difficulties

Significant defect related recombination

Poor solubility of N in GaAs

5 component system

Harder to make Bragg mirrors by MBE

#### Conclusion

- □ Good T characteristics
- All epitaxial growth
- Best contender for low-cost telecom VCSELs

# Thank you

#### References

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